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L31	0

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L32

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result set

*DB=TDBD; PLUR=YES; OP=OR*L32   L310   L32*DB=DWPI; PLUR=YES; OP=OR*L31   L300   L31*DB=JPAB; PLUR=YES; OP=OR*L30   L290   L30*DB=EPAB; PLUR=YES; OP=OR*L29   L280   L29*DB=USOC; PLUR=YES; OP=OR*L28   L270   L28*DB=PGPB; PLUR=YES; OP=OR*L27   L260   L27*DB=USPT; PLUR=YES; OP=OR*L26   L25 and (gate near6 fin)11   L26L25   L24 and (nitride near5 oxide)14   L25

<u>L24</u>	L19 near8 ("oxide" near5 top)	19	<u>L24</u>
<u>L23</u>	L21 and (gate near7 fin)	83	<u>L23</u>
<u>L22</u>	L21 and (gate same ("top surface" near4 "bottom surface"))	13	<u>L22</u>
<u>L21</u>	L20 and nitride	1805	<u>L21</u>
<u>L20</u>	L19 and "oxide"	6784	<u>L20</u>
<u>L19</u>	"fin"	56874	<u>L19</u>
<u>L18</u>	"GERMANIUM FIN"	0	<u>L18</u>
<u>L17</u>	L15	0	<u>L17</u>
<i>DB=TDDB; PLUR=YES; OP=OR</i>			
<u>L16</u>	L15	0	<u>L16</u>
<i>DB=DWPI; PLUR=YES; OP=OR</i>			
<u>L15</u>	L14	0	<u>L15</u>
<i>DB=JPAB; PLUR=YES; OP=OR</i>			
<u>L14</u>	L13	0	<u>L14</u>
<i>DB=EPAB; PLUR=YES; OP=OR</i>			
<u>L13</u>	"high breakdown" and "ratio of increase"	0	<u>L13</u>
<i>DB=USOC; PLUR=YES; OP=OR</i>			
<u>L12</u>	L11	0	<u>L12</u>
<i>DB=PGPB; PLUR=YES; OP=OR</i>			
<u>L11</u>	L10	0	<u>L11</u>
<i>DB=USPT; PLUR=YES; OP=OR</i>			
<u>L10</u>	"high breakdown" and "ratio of increase"	0	<u>L10</u>
<u>L9</u>	6040598	1	<u>L9</u>
<u>L8</u>	L7 and fiber	1	<u>L8</u>
<u>L7</u>	L6 and control\$5	2	<u>L7</u>
<u>L6</u>	L4 and (plasma near4 damage)	2	<u>L6</u>
<u>L5</u>	L4 and "plasma damage"	1	<u>L5</u>
<u>L4</u>	L3 and (charg\$5 near5 wafer)	23	<u>L4</u>
<u>L3</u>	L2 and ("spectrometer" near6 (optical near emission\$))	69	<u>L3</u>
<u>L2</u>	"plasma chamber"	4013	<u>L2</u>
<u>L1</u>	6673200	1	<u>L1</u>

END OF SEARCH HISTORY